Modeling and Design of Molecular Materials 2010

conference organized in Wroclaw, Poland, July 4-8, 2010 by

Institute of Physical & Theoretical Chemistry Wroclaw University of Technology, Poland

Charles University in Prague, Czech Republic

NSF Interdisciplinary Nanotoxicity Center Jackson State University, Jackson, MS, USA

Wrocaw Networking and Supercomputing Center

Meeting will be devoted to presenting contemporary computational methods along with their applications in molecular modeling, molecular material design, bioinformatics and related fields. Participation of experimentalists interested in application of molecular modeling techniques is encouraged.

Conference topics:

- advances in computational methods
- progress in predicting biomolecular structure
- modeling interactions in molecular materials
- modeling materials for hydrogen storage
- rational drug design
- modeling reaction mechanisms
- · catalyst and biocatalyst design
- modeling materials for nanotechnology
- modeling biomolecules

Proceedings:

Refereed conference contributions will be published in Journal of Molecular Modeling (indexed by ISI).

Honorary Scientific Committee:

- T. Brinck Royal Inst. Technol, Stockholm, Sweden
- J. Burda Charles Univ., Prague, Czech Republic
- H. Cheng National University of Singapore
- H. Chojnacki Wroclaw Univ. of Technology
- T. Clark Erlangen-Nurnberg University, Germany
- S. Guccione University of Catania, Italy
- Z. Latajka Wroclaw University
- J. Leszczynski Jackson State Univ, USA CHAIR
- A. Matynia Wroclaw Univ. of Technology
- J. Sauer Humboldt University, Germany
- M. Samoc Wroclaw Univ. of Technology
- O. Shishkin Institute of Single Crystals, Ukraine
- W. A. Sokalski Wrocław Univ. of Technology
- A. Tachibana Kyoto Univ., Japan

Springer Publishing House will sponsor prizes in the best student poster competition.

March 30, 2010 — Registration and early fee payment May 15, 2010 — Abstracts and late fee payment July 4–8, 2010 — Meeting

List of speakers:

- T. Brinck Stockholm, Sweden
- J. Bujnicki Warsaw, Poland
- J. Burda Prague, Czech Republic
- H. Cheng Singapore
- T. Cierpicki Ann Arbor, USA
- I. Cukrowski Pretoria, S. Africa
- C. Ghio Pisa, Italy
- J. Grembecka Ann Arbor, USA
- S. Filipek Warsaw, Poland
- W. Grochala Warsaw, Poland
- P. Kozlowski Louisville, KY, USA
- Z. Latajka Wroclaw, Poland
- B. Lesyng Warsaw, Poland
- A. Lodola Parma, Italy
- A. Michalak Cracow, Poland
- V. Moliner Castellon de la Plana, Spain
- J. Murray Cleveland, OH, USA
- M. Neumann Saint-Germain-en-Laye, France
- P. Paneth Lodz, Poland
- P. Politzer New Orleans, LA, USA
- S. Roszak Wrocław, Poland
- M. Samoc Wroclaw, Poland
- O. Shishkin Kharkov, Ukraine
- A. Tachibana Kyoto, Japan
- K. Yoshizawa Fukuoka, Japan

Detailed information, program and registration form are available on the web page http://mdmm.pl/2010

Correspondence should be sent to:

MDMM 2010 conference
Institute of Physical and Theoretical Chemistry I-30
Department of Chemistry
Wroclaw University of Technology
Wybrzeze Wyspianskiego 27
50-370 Wroclaw, Poland
tel: +48 (71) 320 2457; fax: +48 (71) 320 3364
mdmm@mdmm.pl

MDMM2010 conference will be preceded by:
Computational Molecular Science 2010 meeting
Cirencester, UK, June 27–30, 2010; http://www.chm.bris.ac.uk/cms
and followed by 18-th International Conference on Phosphorus Chemistry
Wroclaw, Poland, July 11–15, 2010; http://icpc2010.pwr.wroc.pl
and 8-th European Conference on Computational Chemistry
Lund, Sweden 25-28 August, 2010; http://www.chemsoc.se/sidor/KK/8thECCC/index.htm